

Special Issue

Micro/Nano Manufacturing II

Message from the Guest Editors

Micromanufacturing deals with the fabrication of structures in the order of 0.1 to 1000 μm . The scope of nanomanufacturing extends the size range of manufactured features to even smaller length scales below 100 nm. Both micro and nanomanufacturing can be considered as important enablers for high-end products. Especially, such products are enabled by micro and nanofeatures and structures to incorporate special optical, electronic, mechanical, fluidic or biological functions in existing and new emerging products and thus lead to unique selling points. This Special Issue is dedicated to recent advances in research and development within the field of micro- and nanomanufacturing. Therefore, papers are welcome that report recent findings and advances in manufacturing technologies for producing products with micro- and nanoscale features and structures. Furthermore, papers that report applications underpinned by advances in these technologies are also welcomed. Dr. Steffen Gerhard Scholz

Guest Editors

Prof. André Zimmermann

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Deadline for manuscript submissions

closed (20 May 2020)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

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